



E-MRS 2016 Spring Meeting



**Selective growth of ZnO nanosheets
and their application in piezoelectric
and triboelectric energy harvesting
devices**



**Symposium W
Lille, May 5, 2016**

sinergy-project.eu

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SiNERGY

Silicon Friendly Materials and Device Solutions
for Microenergy Applications

Introduction

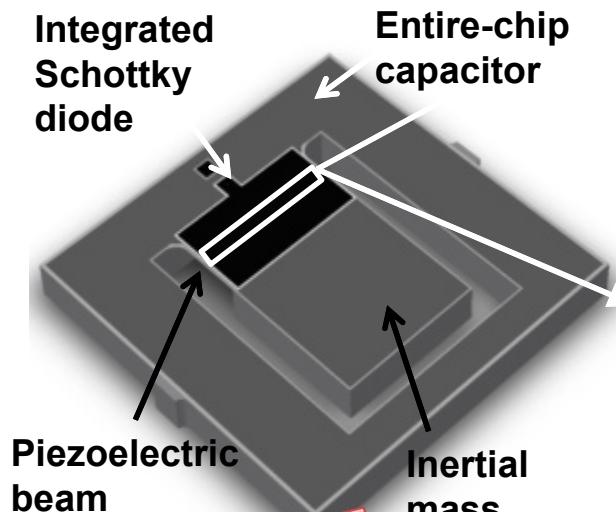


European Union
Horizon 2020 Innovation Fund



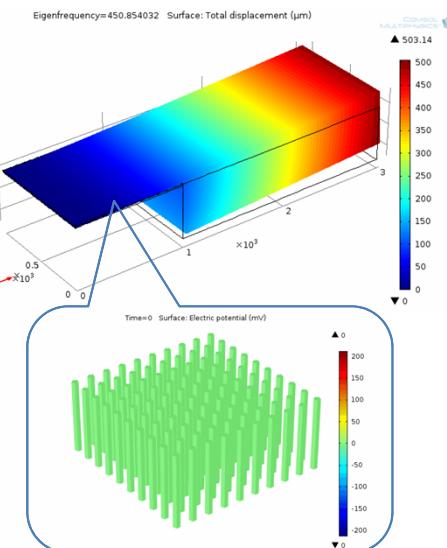
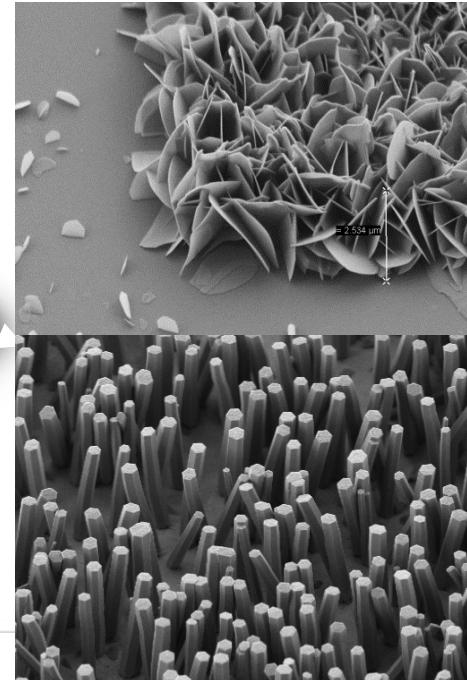
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- Piezoelectric Energy Harvesters: our final target
 - Silicon mass and cantilever beam based on DRIE of an SOI wafer
 - **ZnO nanostructures** (nanowire and nanosheet) as piezoelectric material
 - Polymer encapsulation of NW/NS network
 - **Monolithically integrated Schottky diode and capacitor**



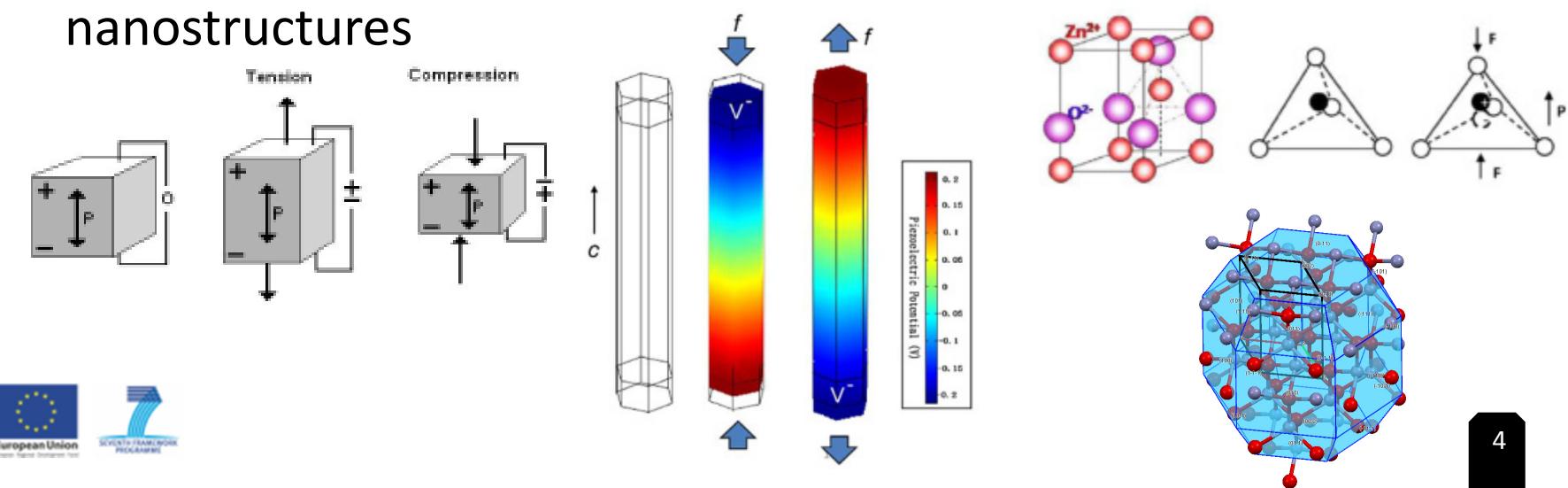
Seventh Framework Programme

PATENT
PENDING



- Why ZnO nanostructures?

- ZnO is a semiconductor that presents a piezoelectric behavior and direct band-gap
- ZnO nanostructures are easy to grow and integrate with silicon
- More flexible and robust than thin-films
- Compatible with VLS silicon technologies
- ZnO is also a hot-topic and low-cost solution to grow nanostructures





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Growth of ZnO nanosheets (NSs) and nanowires (NWs)

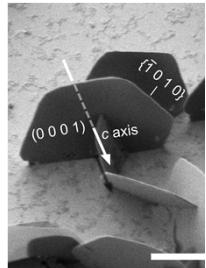
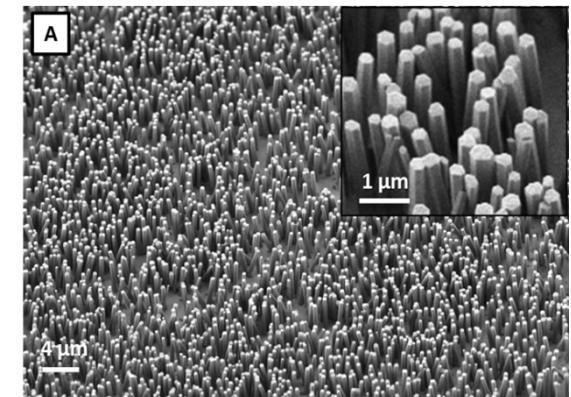
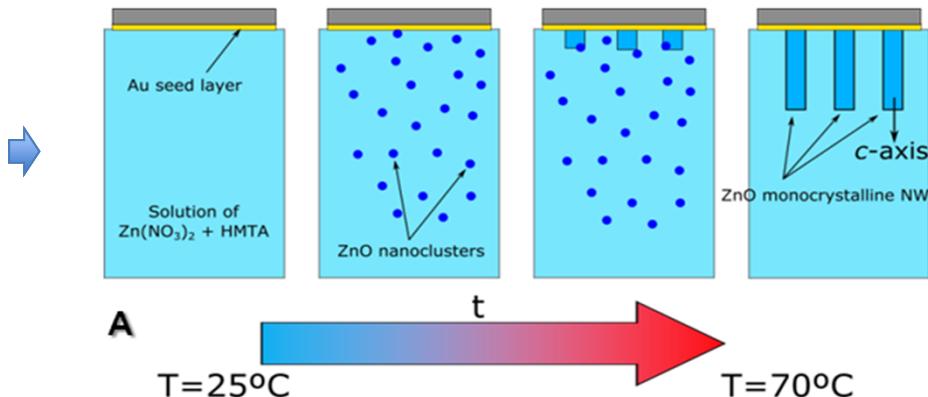
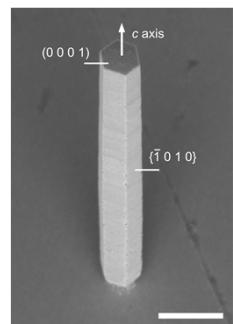


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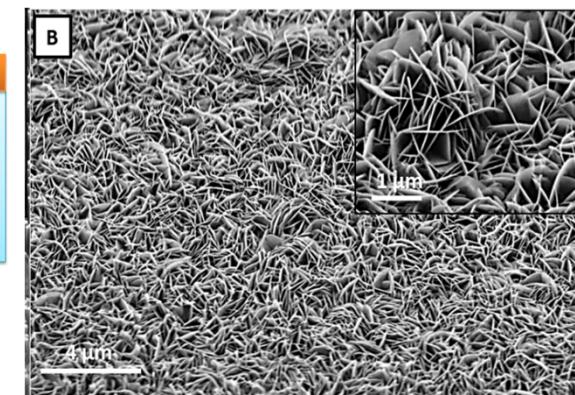
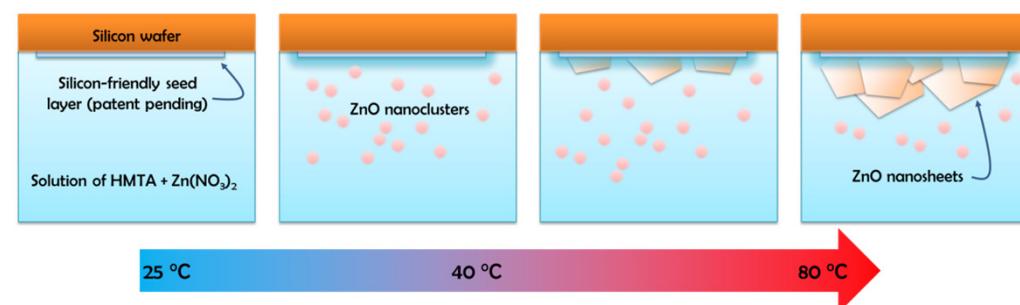


Hydrothermal method for ZnO nanostructures

Hydrothermal process (cheap, low T, wafer level and selective)



NS

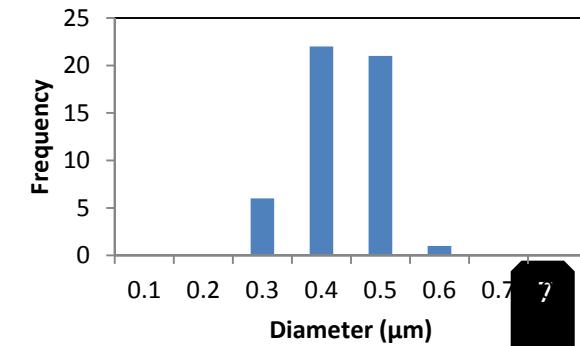
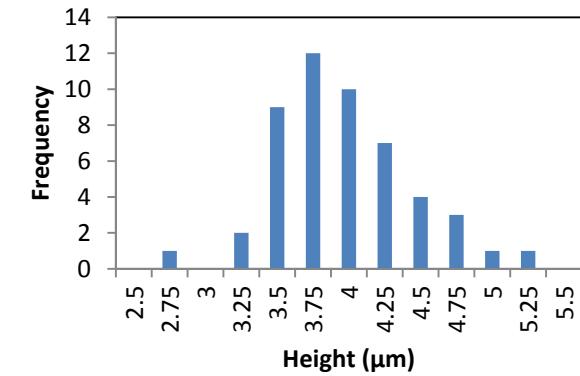
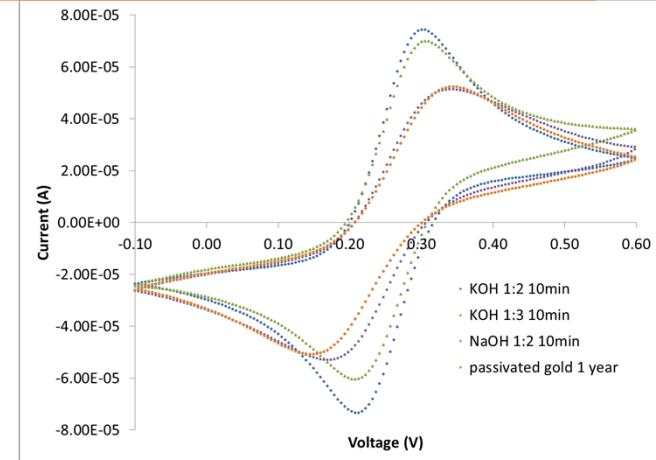
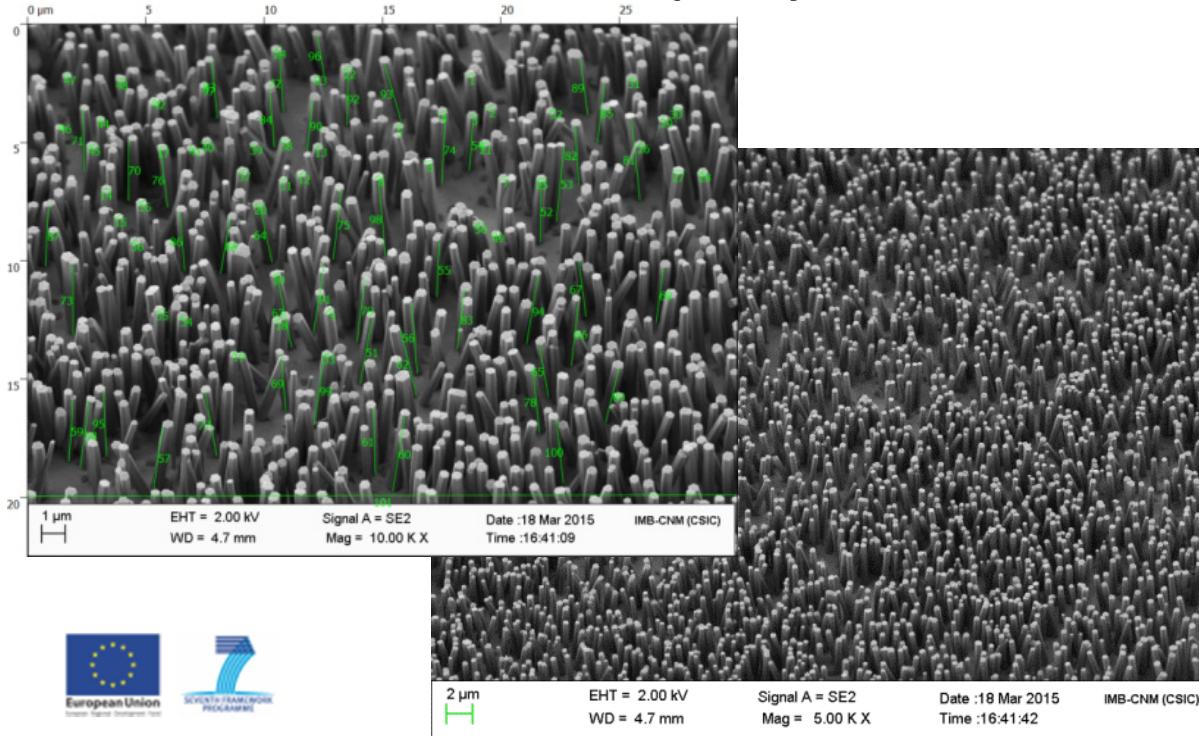




ZnO NW synthesis: activation method

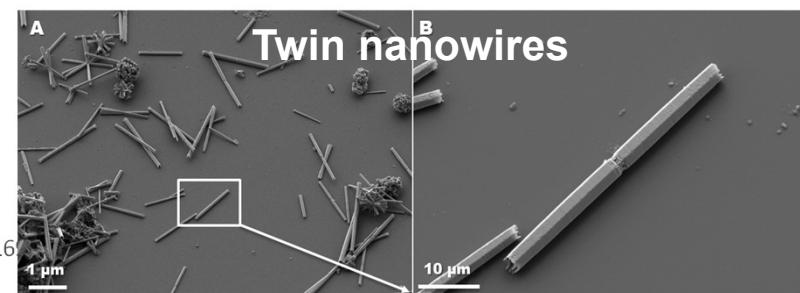
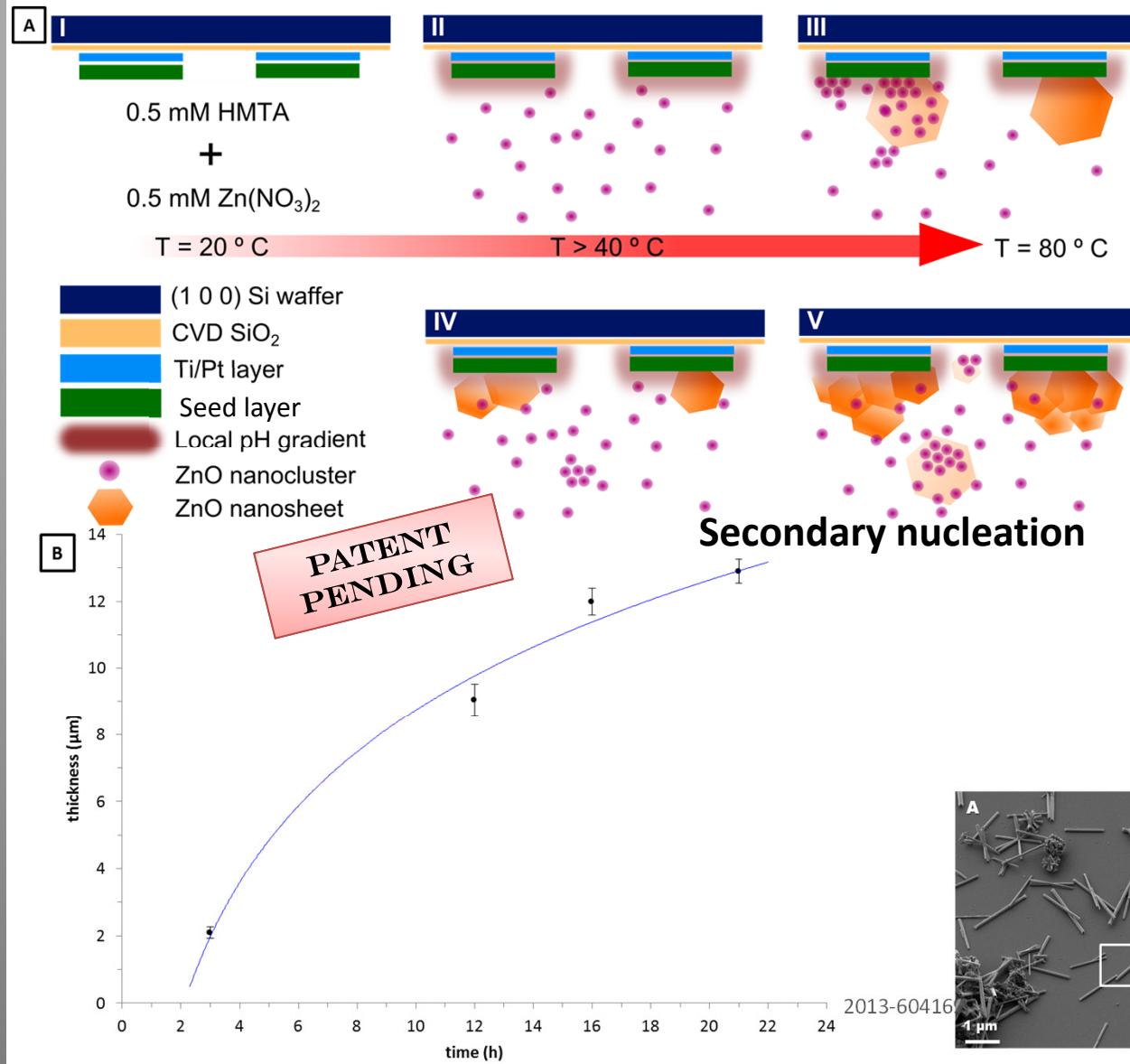
Growth Characterization of NW over gold seed layer Density = 124 NW/100 μ m²

- Activation process developed with H₂O₂:KOH (1:3 and 1:2), H₂O₂:NaOH (1:3 and 1:2) or HNO₃.
- Relationship between cyclic voltammetry and surface cleanliness and quality**





ZnO NS synthesis: working principle

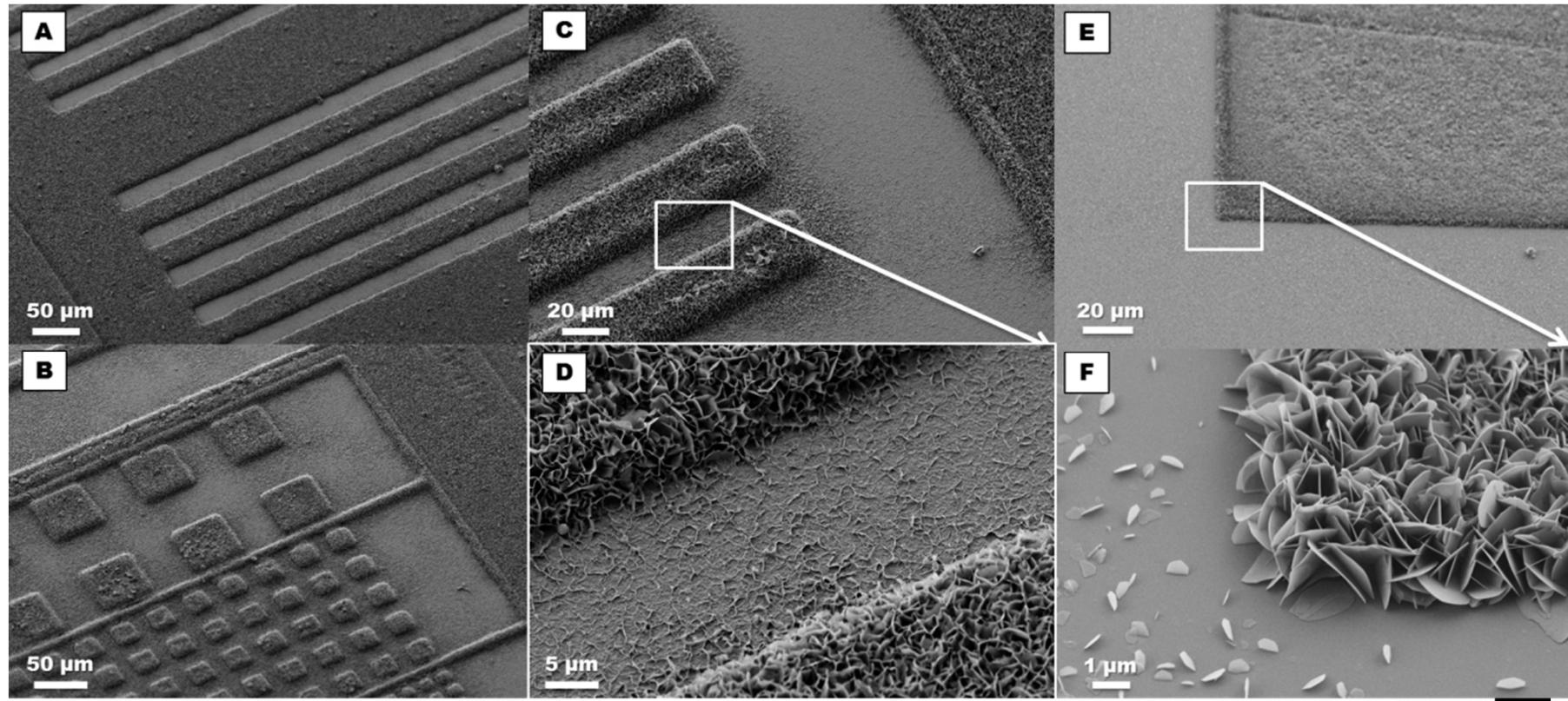
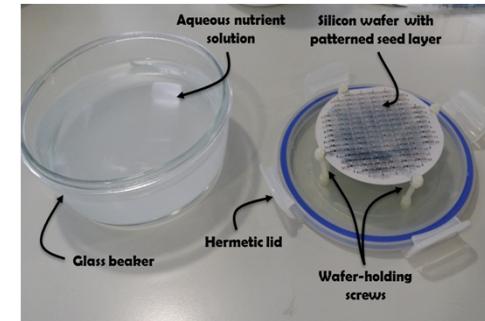




Selective area ZnO NS synthesis at wafer level

Selective area growth on silicon wafers

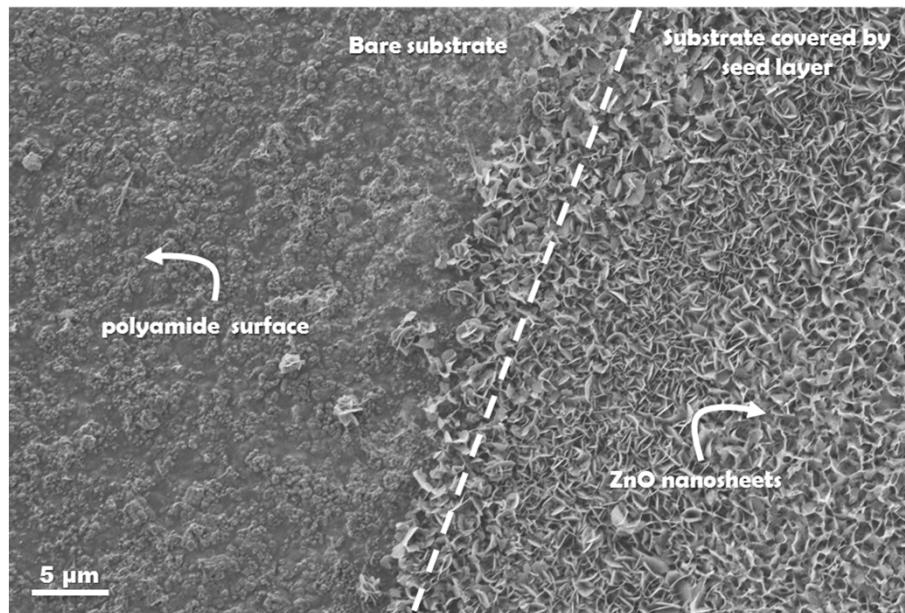
- Micrometric features can be obtained with high selectivity at wafer level.





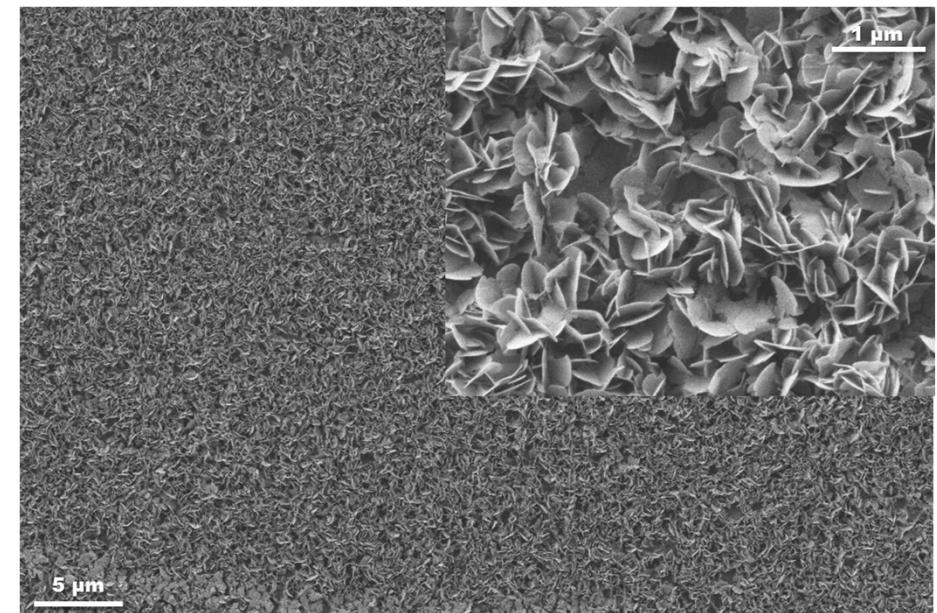
ZnO NS synthesis on other substrates

- Performed in flexible substrates such as polyimide
- It can be grown on top of glass (transparent device)
- Wafer-level synthesis



polyimide

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glass



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Material characterization



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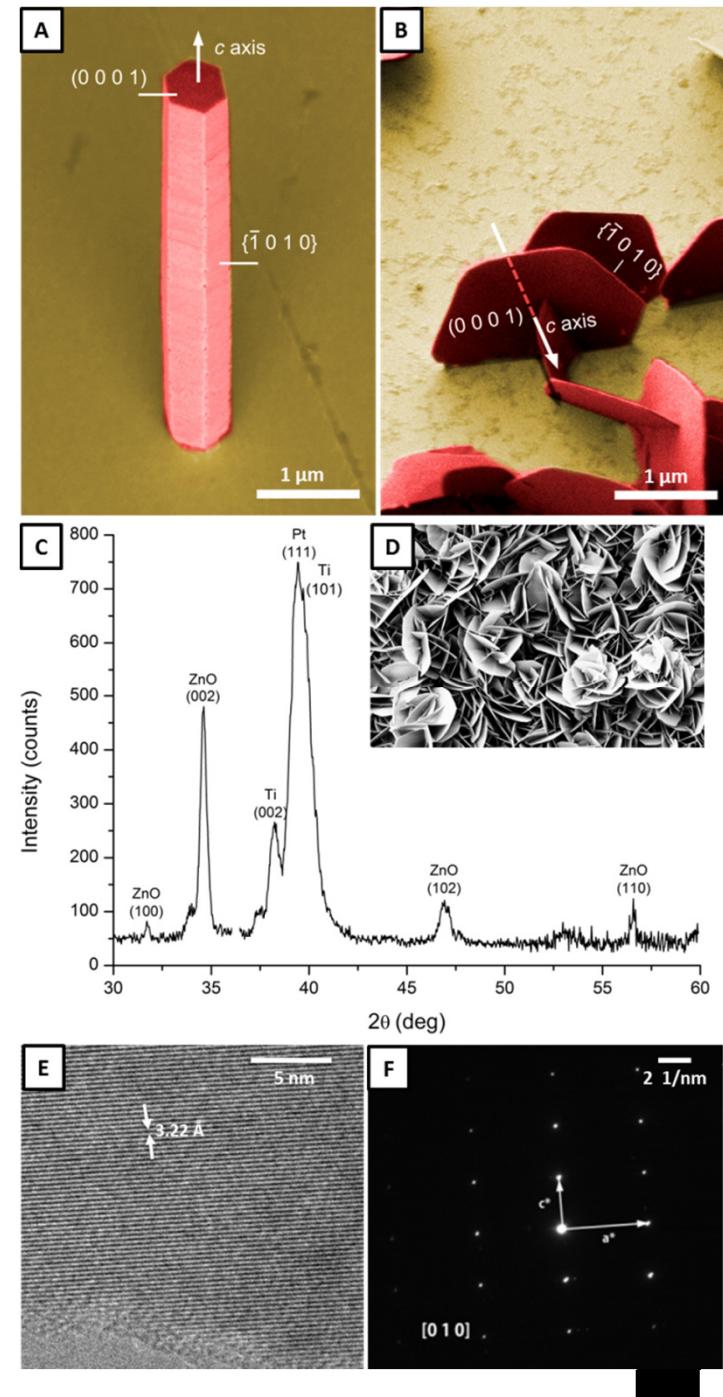
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ZnO NS vs. NW

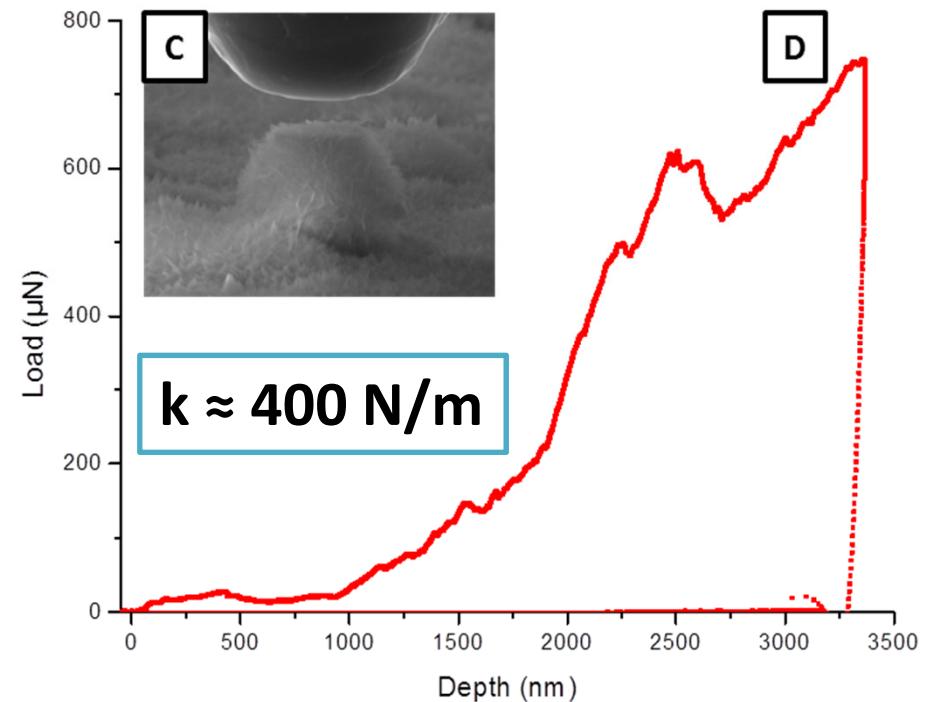
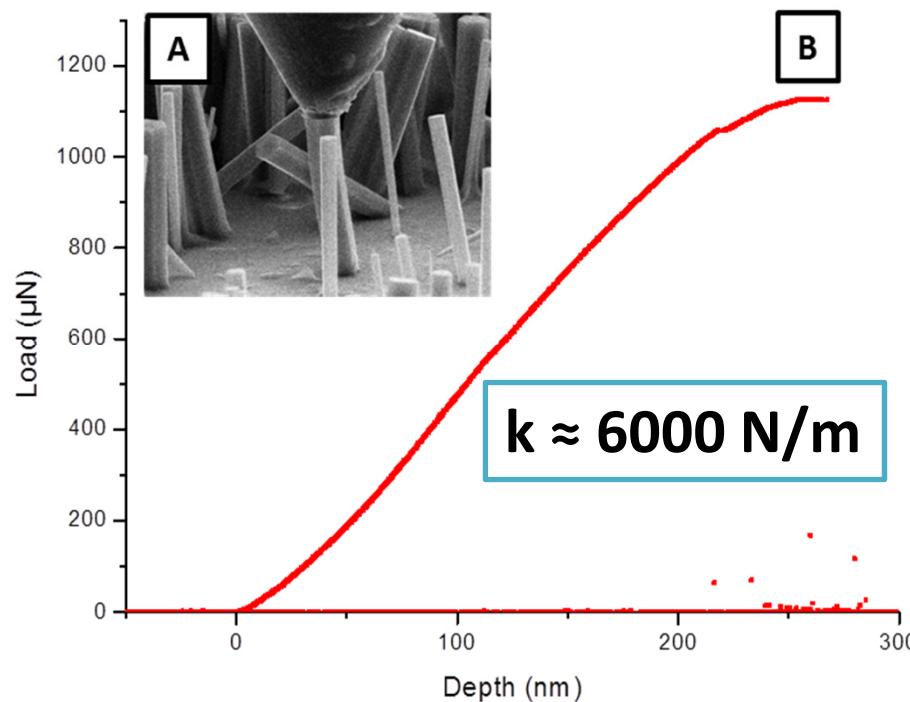
Characterization by HRTEM, SEM and XRD:

- ZnO NWs & NWs show a **good crystalline structure**.
- NS: Thickness < 20 nm, several μm long; **high aspect ratio**
- NS: Extremely high-density, **reproducible and fast**
- Growth along (0001) face is inhibited by the local pH gradient around seed layer
- **Seed layer is an insulator which avoid screening effect** of external carriers going into the ZnO



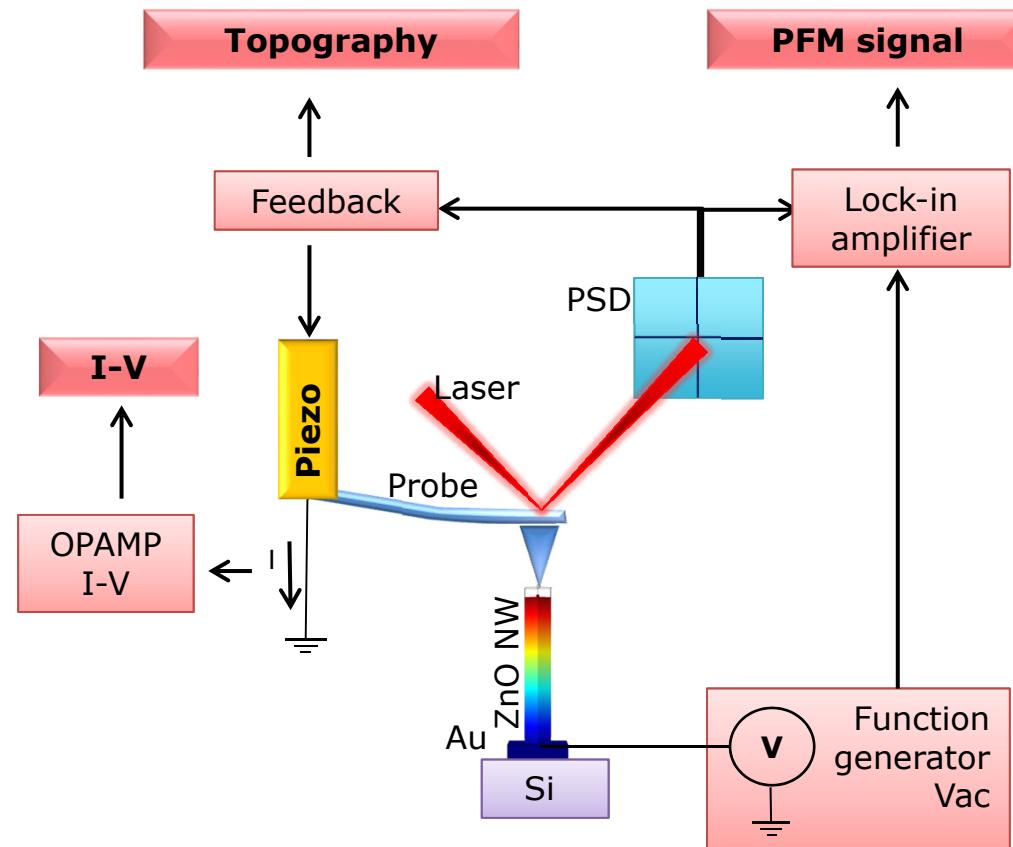
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- ZnO nanostructures allow higher compression without fracture.
- It has been demonstrated that a single ZnO NW can stand for a compressing force of more than 1mN!



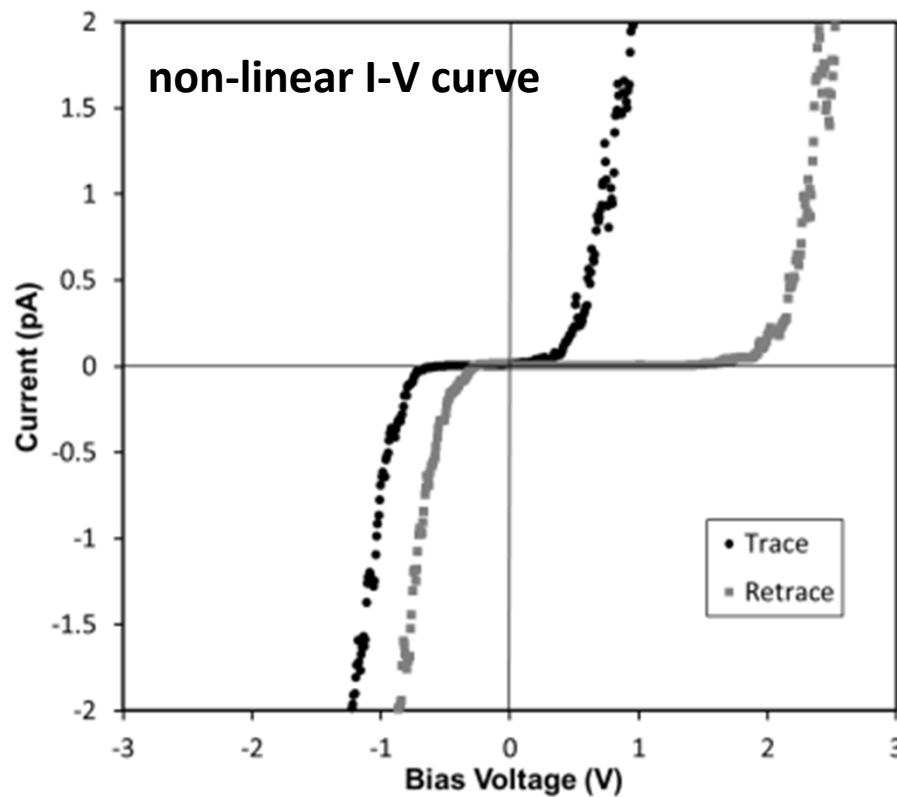
Piezoresponse Force Microscopy (PFM):

- AFM technique based on the converse piezoelectric effect
- Conductive tip used to measure the mechanical response when an electrical voltage (usually ac-voltage) is applied to the surface

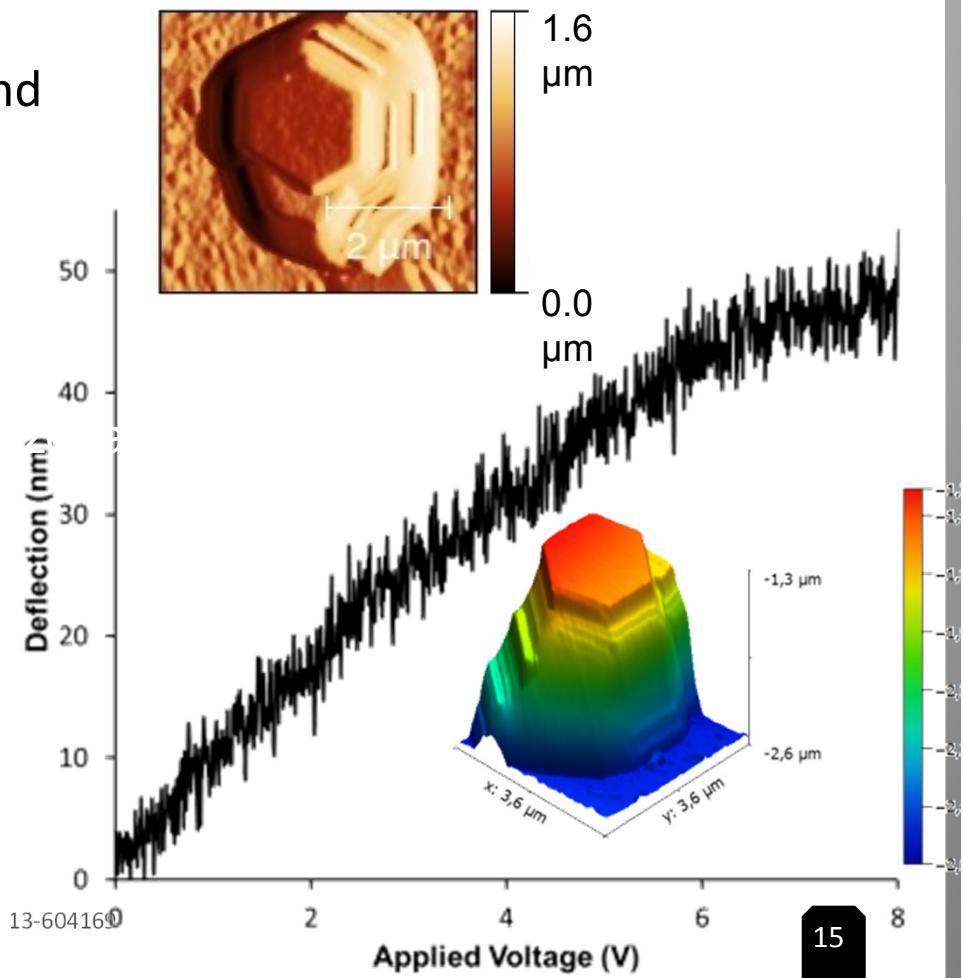


- I-V and piezoresponse characterization

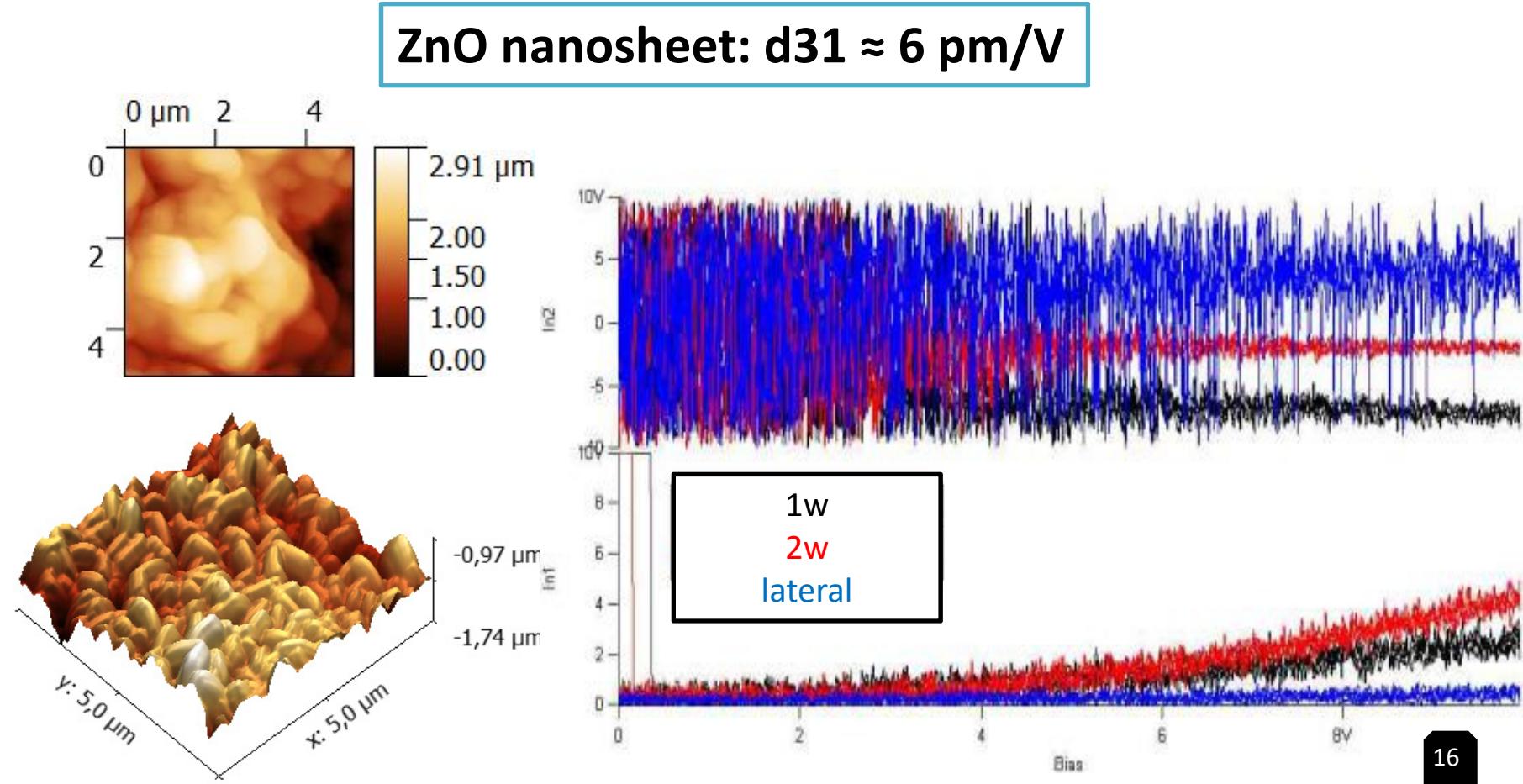
Piezoresponse AFM (PFM)
measurement of ZnO nanowires and
nanosheets at 37kHz.



ZnO nanowire: $d_{33} \approx 8.6 \text{ pm/V}$



- PFM characterization
 - Piezoresponse of ZnO nanowires and nanosheets at 37kHz.





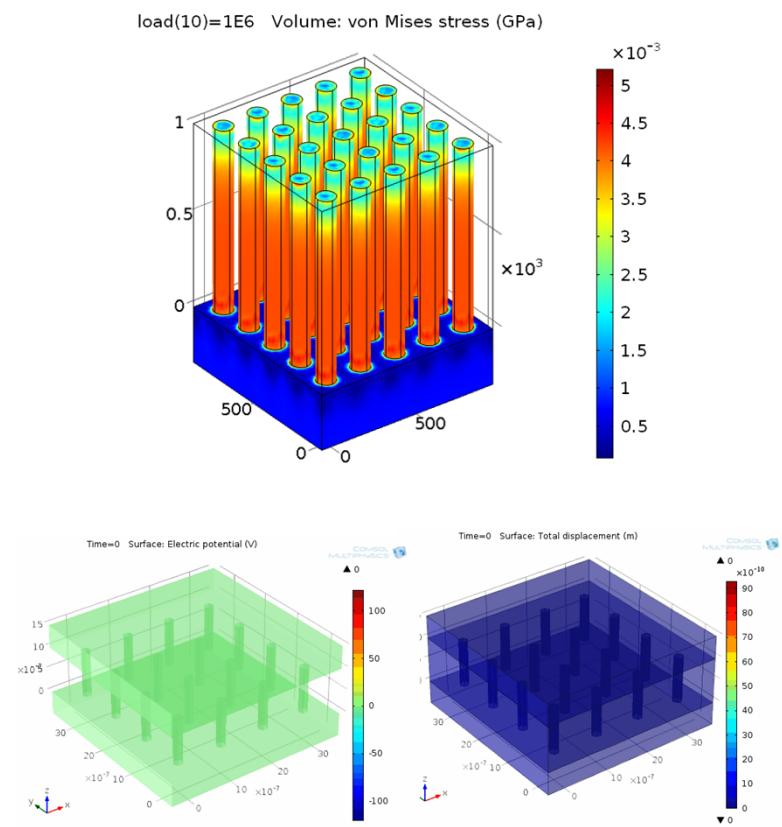
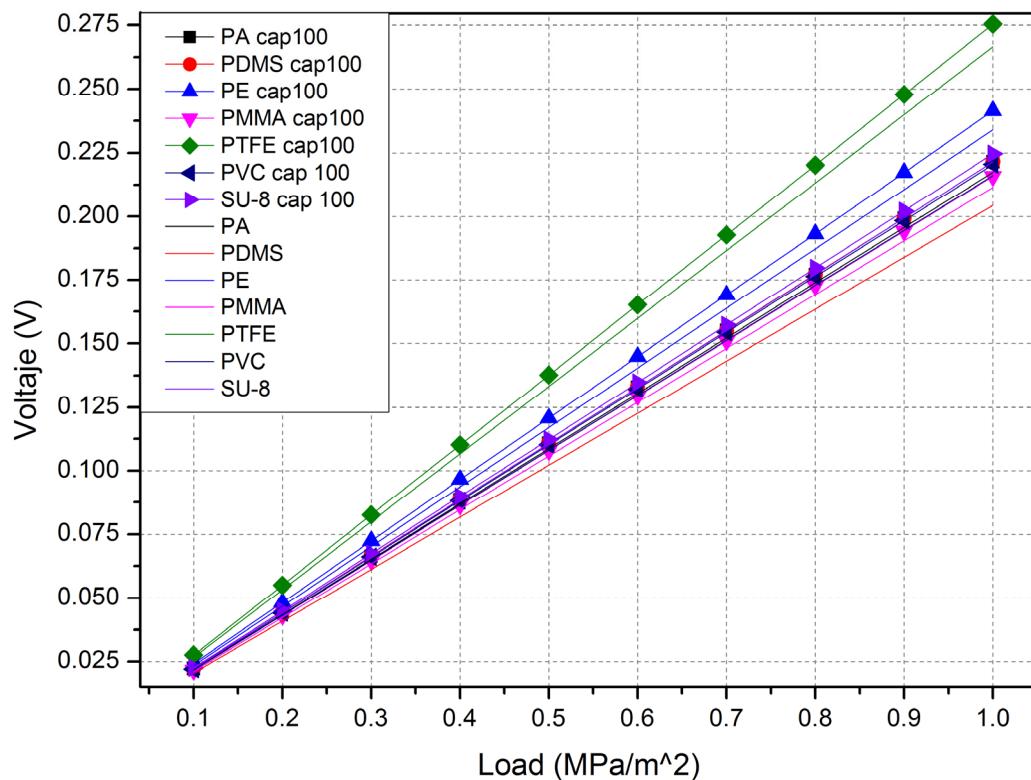
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Piezoelectric and triboelectric applications: preliminary results

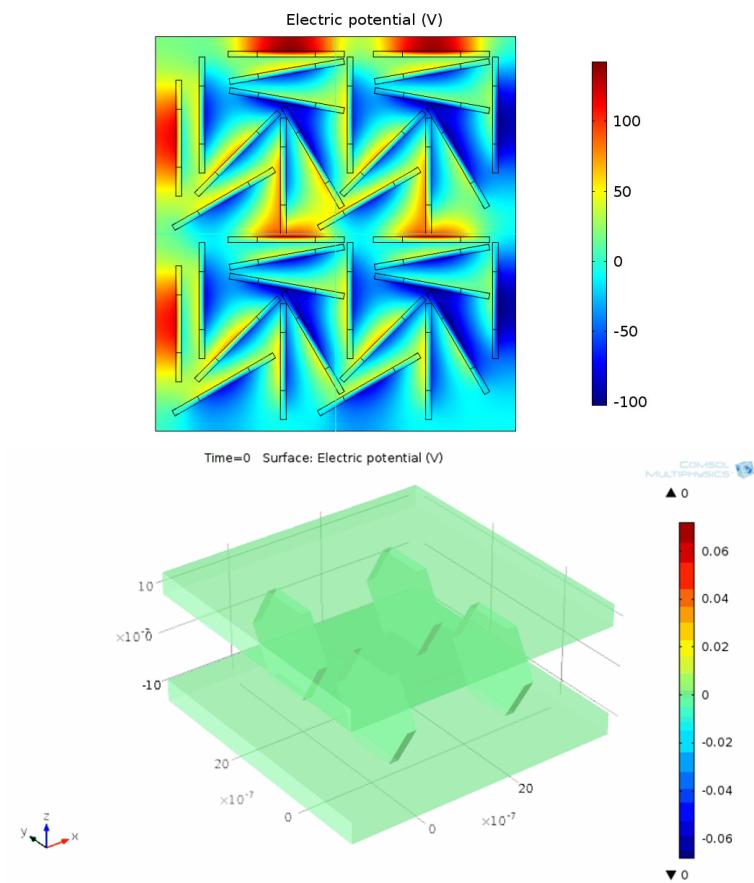
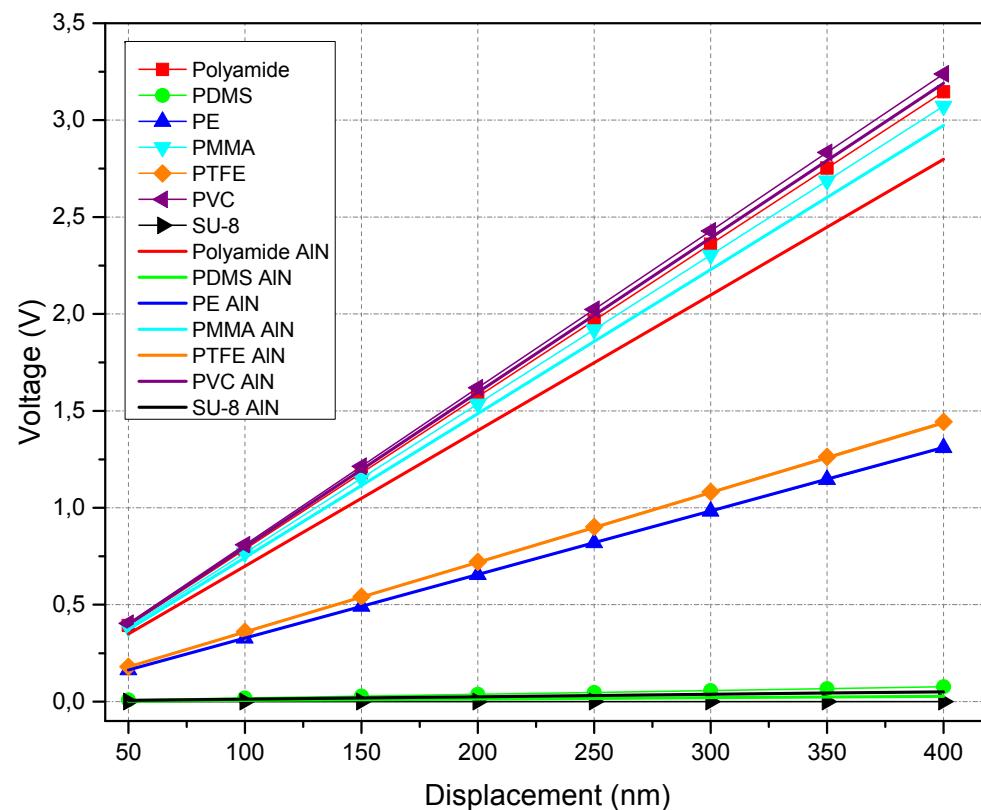


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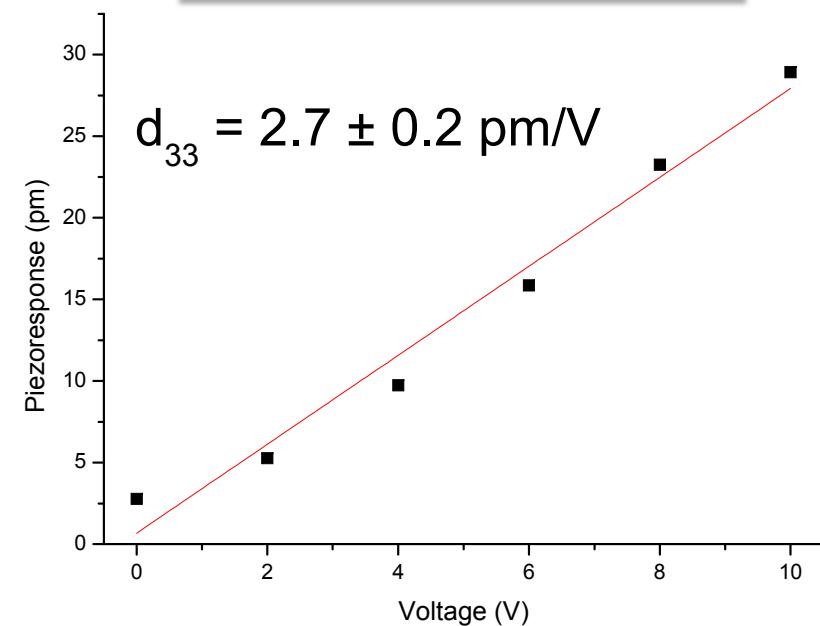
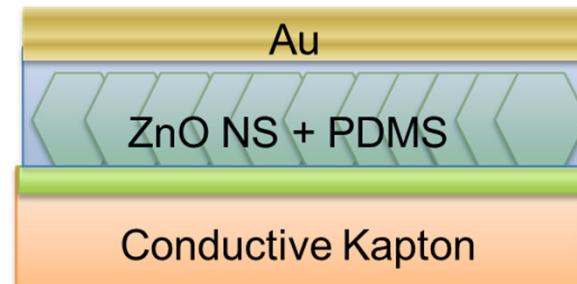
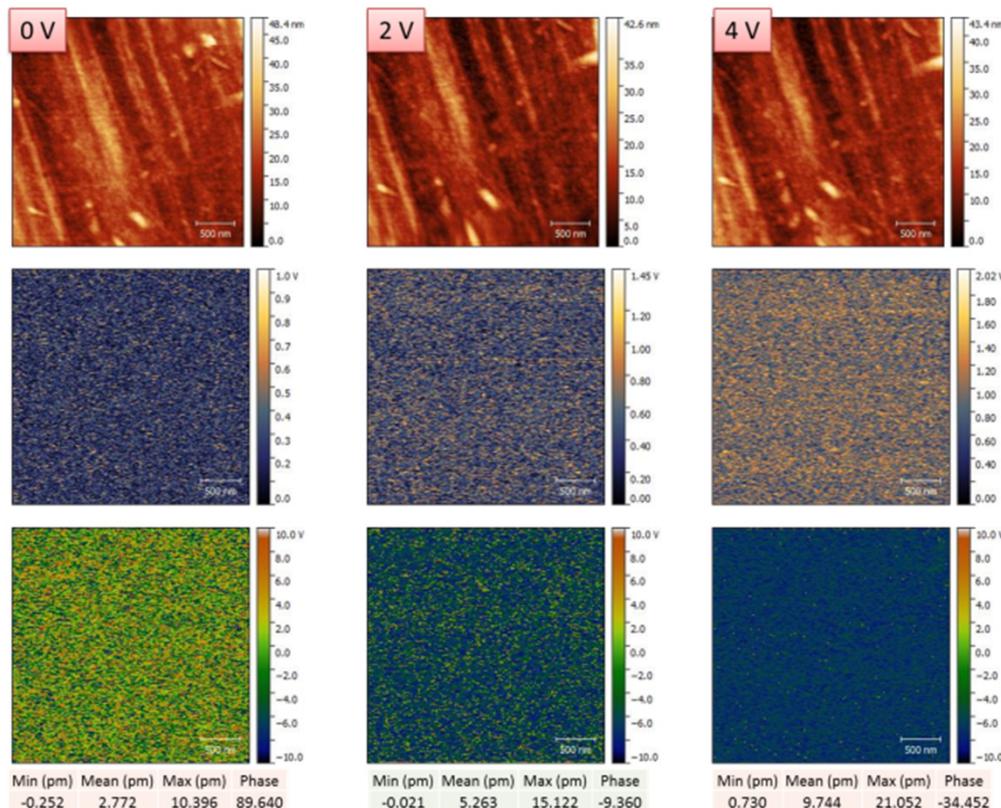
- ZnO nanowires
 - Study of more suitable polymer to encapsulate ZnO NWs in terms of open circuit voltage:



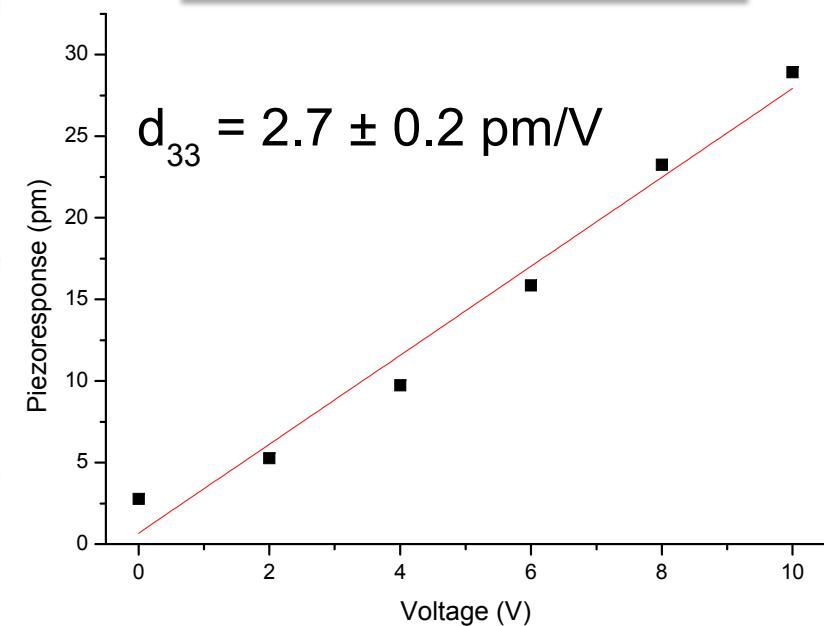
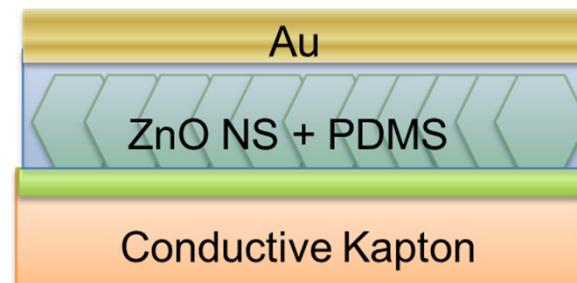
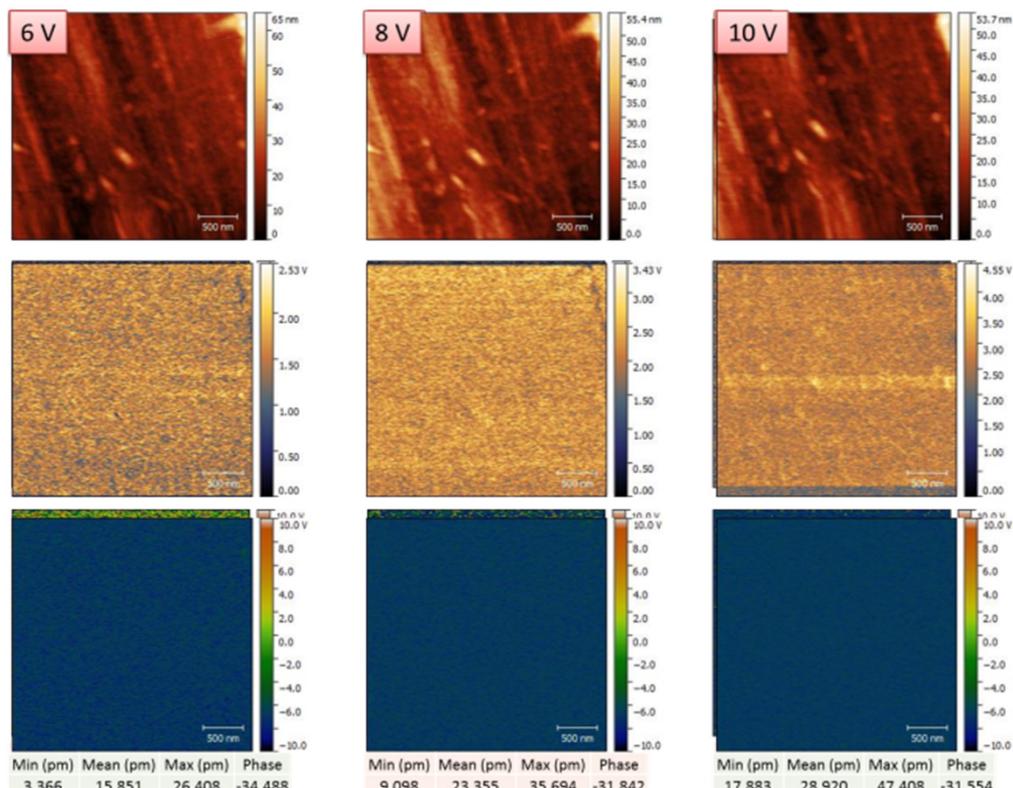
- ZnO nanosheets:
 - Study of more suitable polymer to encapsulate ZnO NSs in terms of open circuit voltage:



PFM of Flexible generator based on ZnO NS + PDMS

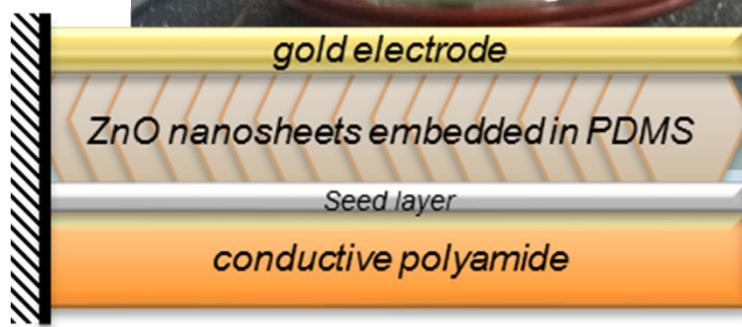
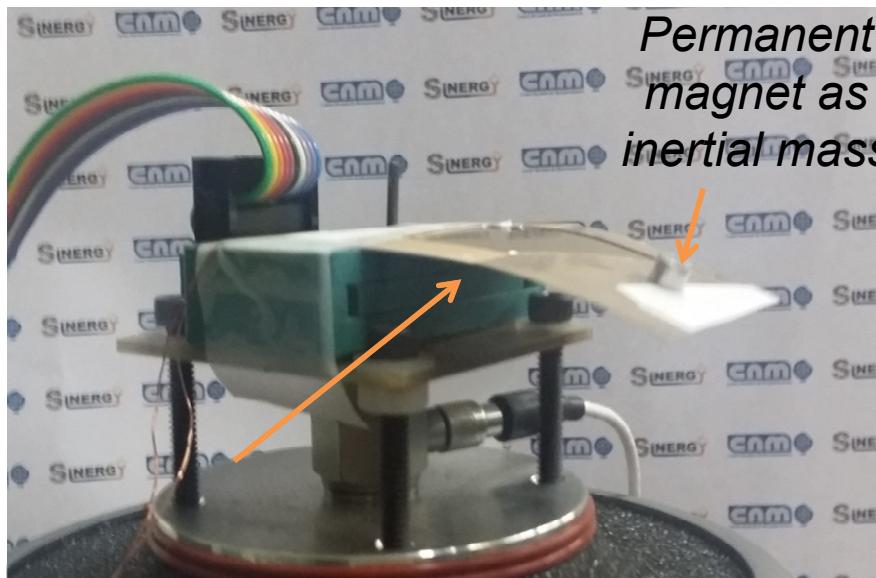


PFM of Flexible generator based on ZnO NS + PDMS

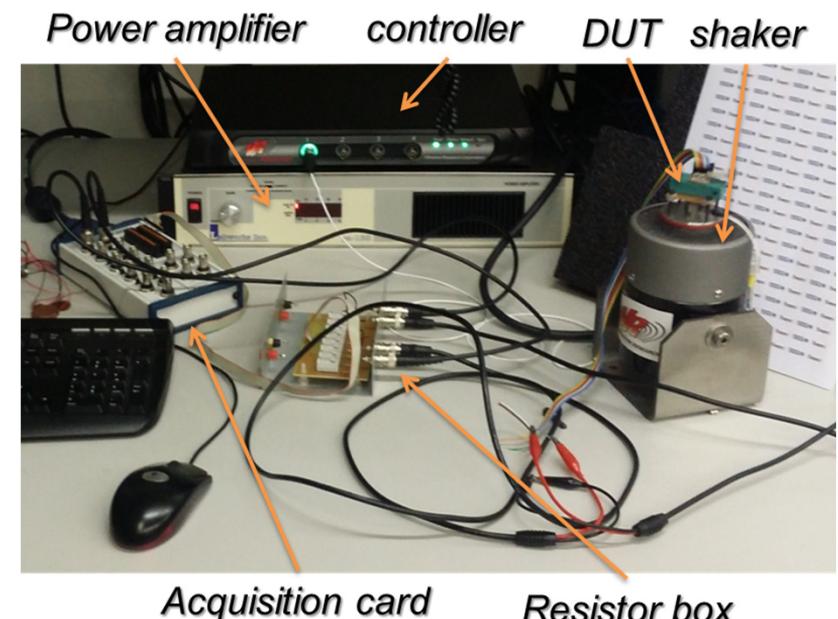


Flexible NS-based prototype

- Flexible energy harvester
 - Vibrational device characterisation
 - Tip mass made with two magnets

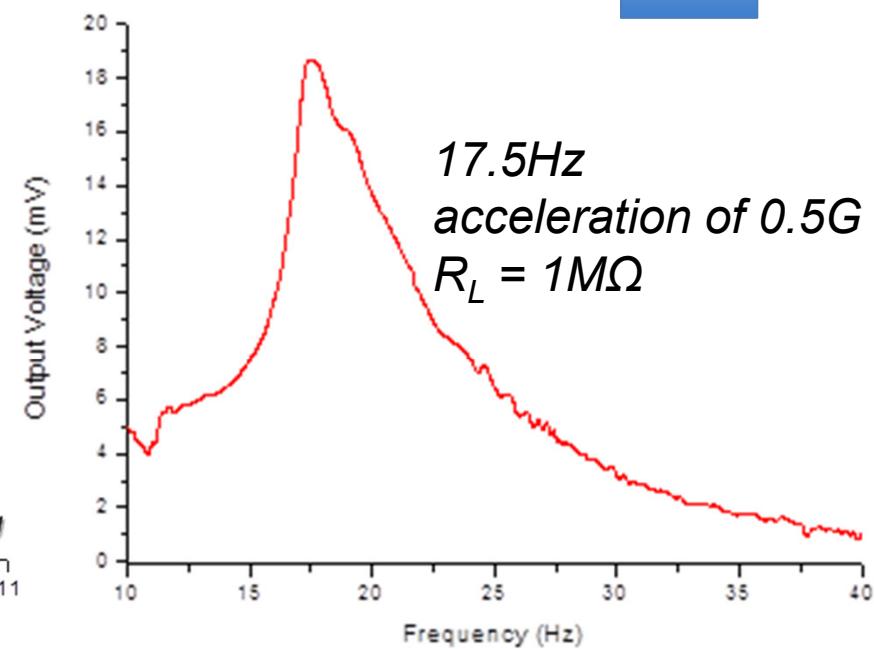
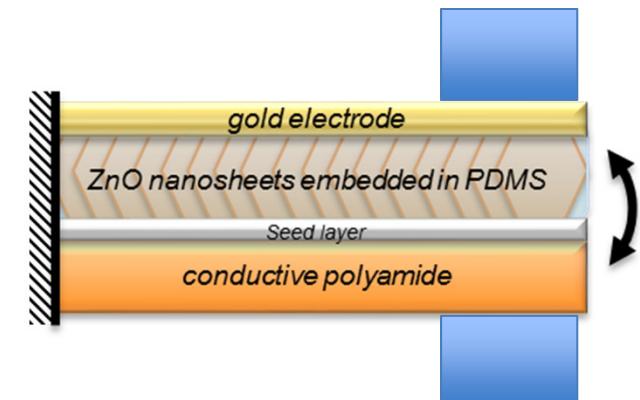
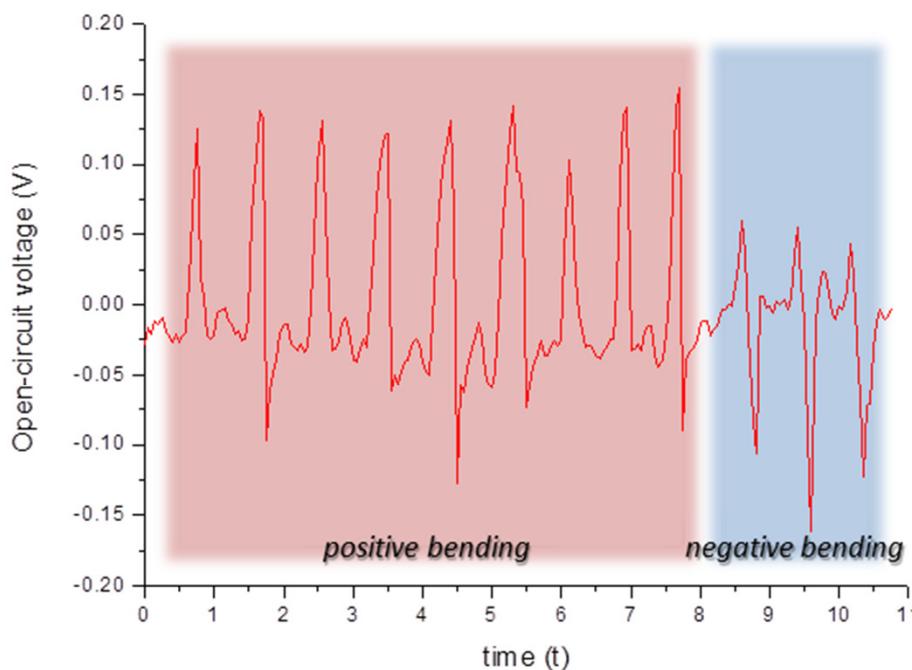


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- Piezoelectric effect

Flexible device mounted on top of an electromagnetic shaker to be tested at a controlled vibration at a certain frequency and acceleration

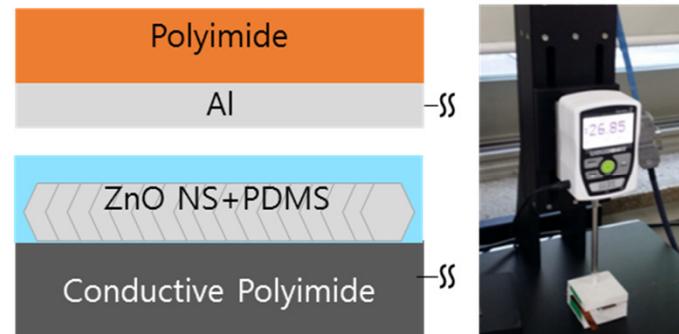




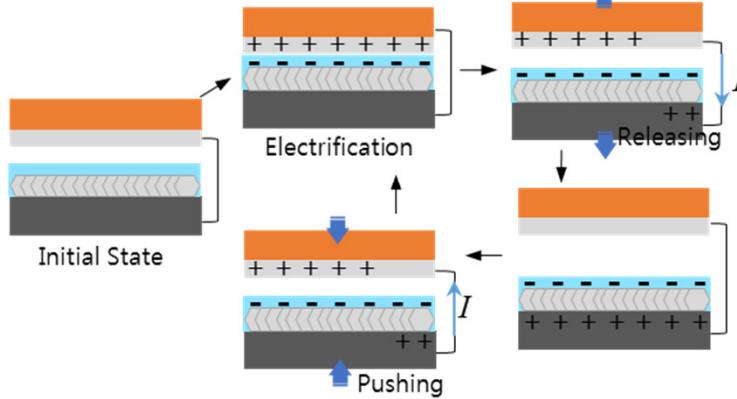
Flexible NS-based prototype

- Triboelectric effect:

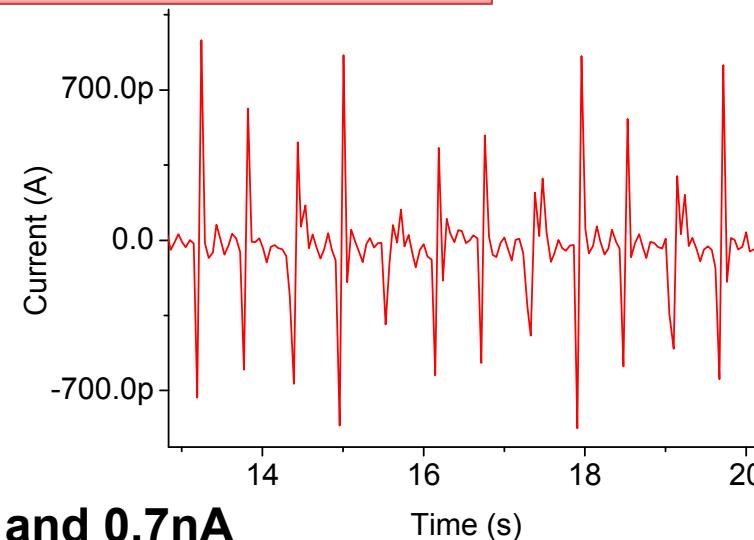
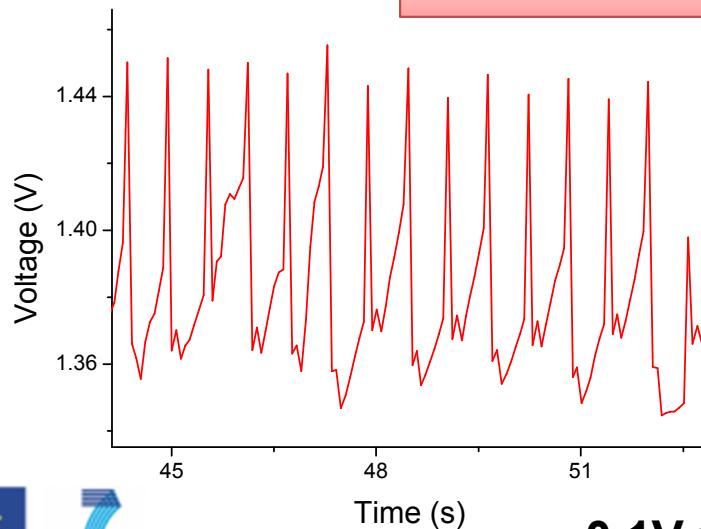
a



b



Close contact: piezoelectric contribution



0.1Vpp and 0.7nA

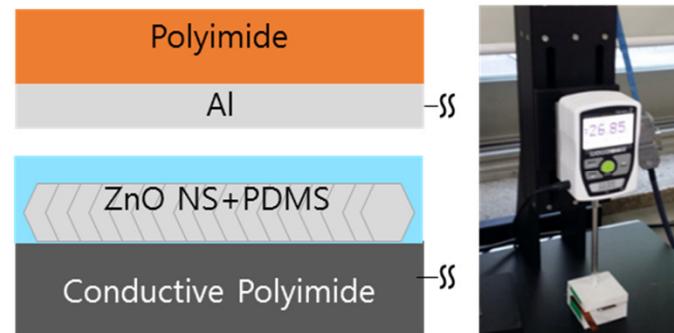




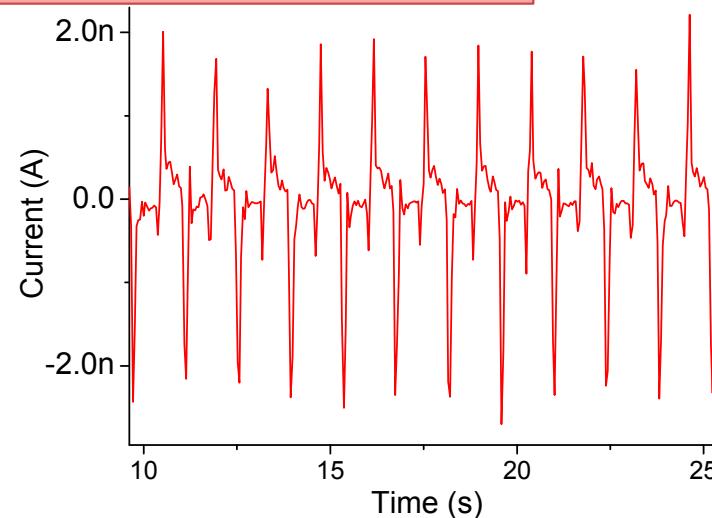
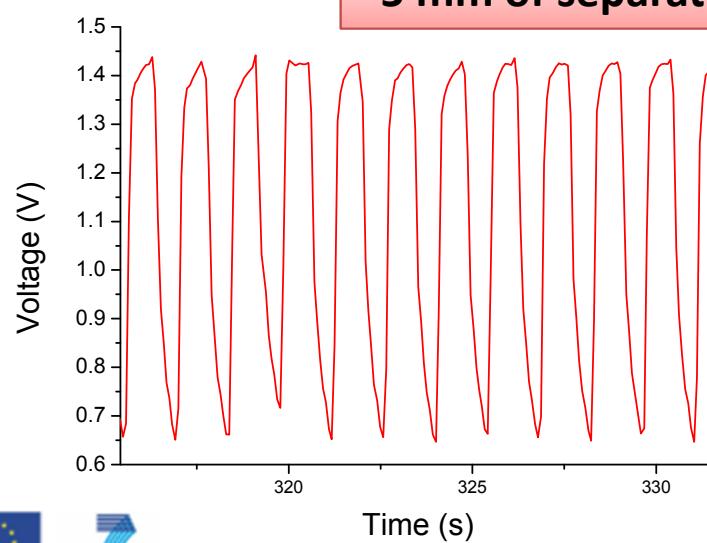
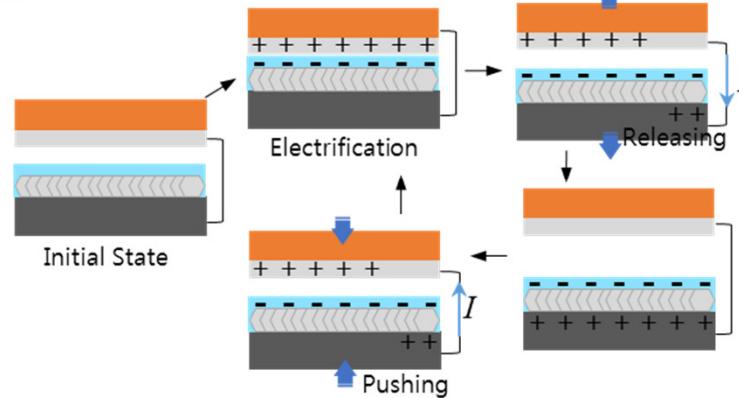
Flexible NS-based prototype

- Triboelectric effect:

a



b



0.78Vpp and 2nA





Conclusions

- Our novel seed layer allows **selective area growth of ZnO NSs**
- This growth is **inexpensive, fast, reproducible, at wafer level** and over transparent, flexible and silicon substrates
- Piezoelectric coefficients of ZnO NWs and NSs have been measured
- A **flexible NS-based prototype** has been fabricated and electrically characterized
- Some preliminary results show a promising application of ZnO NSs in **triboelectric and piezoelectric devices**

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Thank you! Any question?

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